



US00D919114S

(12) **United States Design Patent** (10) **Patent No.:** **US D919,114 S**  
**Teramura** (45) **Date of Patent:** **\*\* May 11, 2021**

(54) **CULTURE DEVICE**  
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(73) Assignee: **JNC CORPORATION**, Tokyo (JP)  
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(21) Appl. No.: **29/676,072**  
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(Continued)

(30) **Foreign Application Priority Data**  
Jul. 11, 2018 (JP) ..... D2018-015363  
(51) **LOC (13) Cl.** ..... **24-02**  
(52) **U.S. Cl.**  
USPC ..... **D24/225**  
(58) **Field of Classification Search**  
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D9/537, 545, 549, 700, 705, 706;  
D3/203.1, 203.2; D10/81; D28/78  
CPC .. B01L 3/0275; B01L 3/5085; B01L 3/50825;  
C12M 23/10; C12M 23/12  
See application file for complete search history.

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(57) **CLAIM**

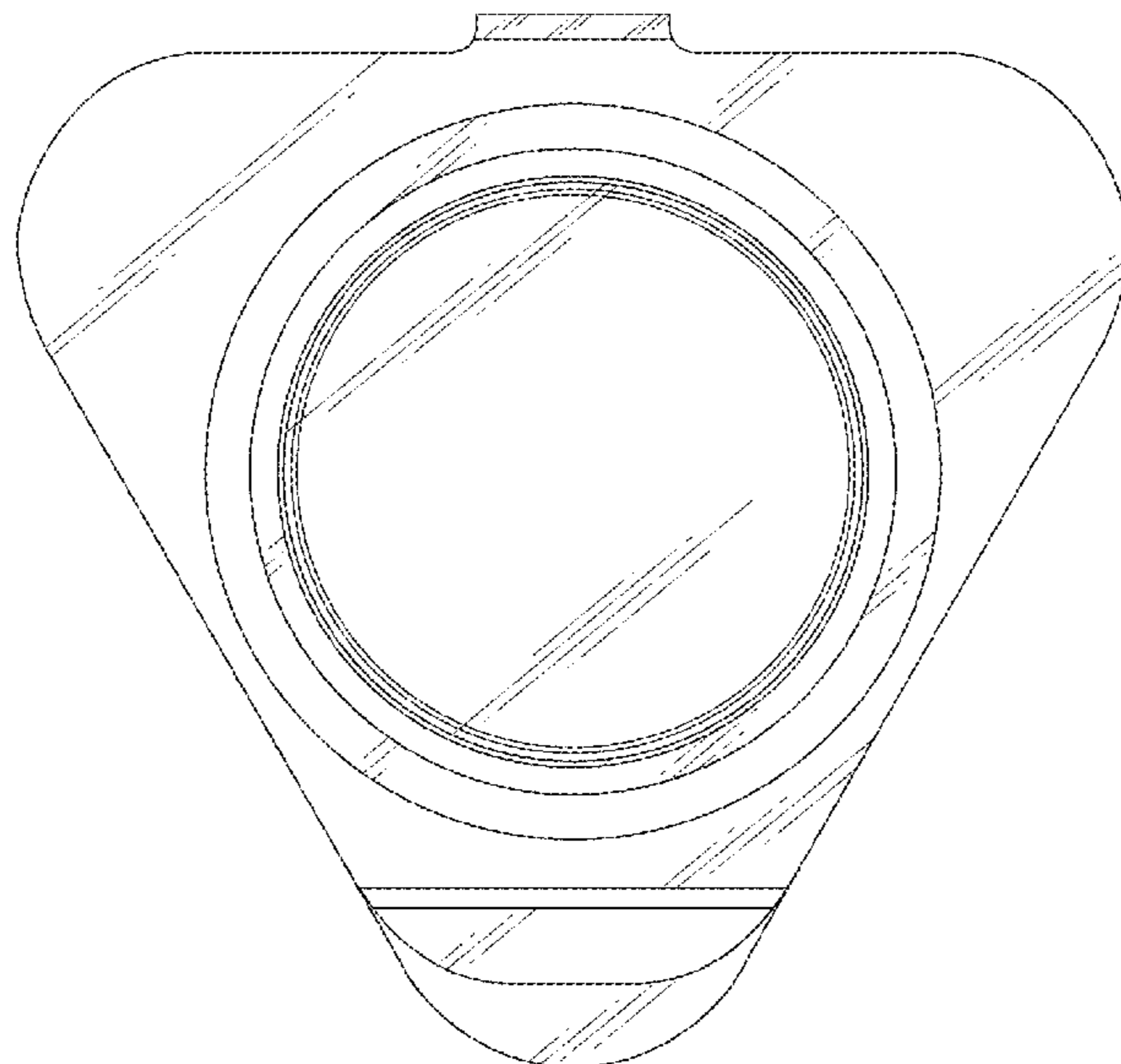
The ornamental design for a culture device, as shown and described.

**DESCRIPTION**

FIG. 1 is a front elevational view of a culture device showing my new design;  
FIG. 2 is a rear elevational view thereof;  
FIG. 3 is a left side elevational view thereof;  
FIG. 4 is a right side elevational view thereof;  
FIG. 5 is a top plan elevational view thereof;  
FIG. 6 is a bottom elevational view thereof;  
FIG. 7 is a cross-sectional view thereof taken along a line 7-7 of FIG. 1;  
FIG. 8 is a front elevational view thereof in an open position; and,  
FIG. 9 is a right side elevational view thereof in an open position.  
The culture device in the present design is entirely transparent.

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**1 Claim, 7 Drawing Sheets**



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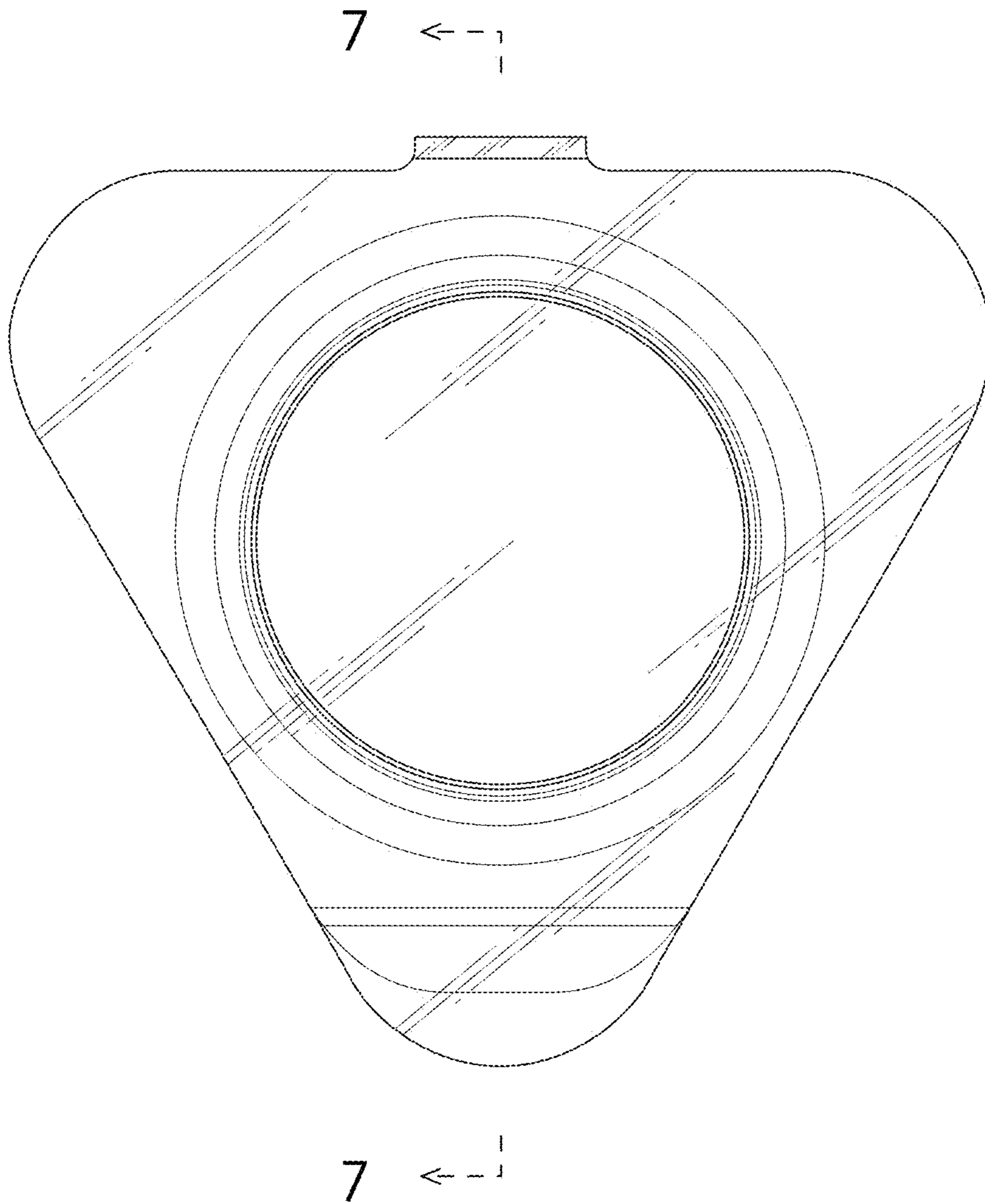


FIG.1

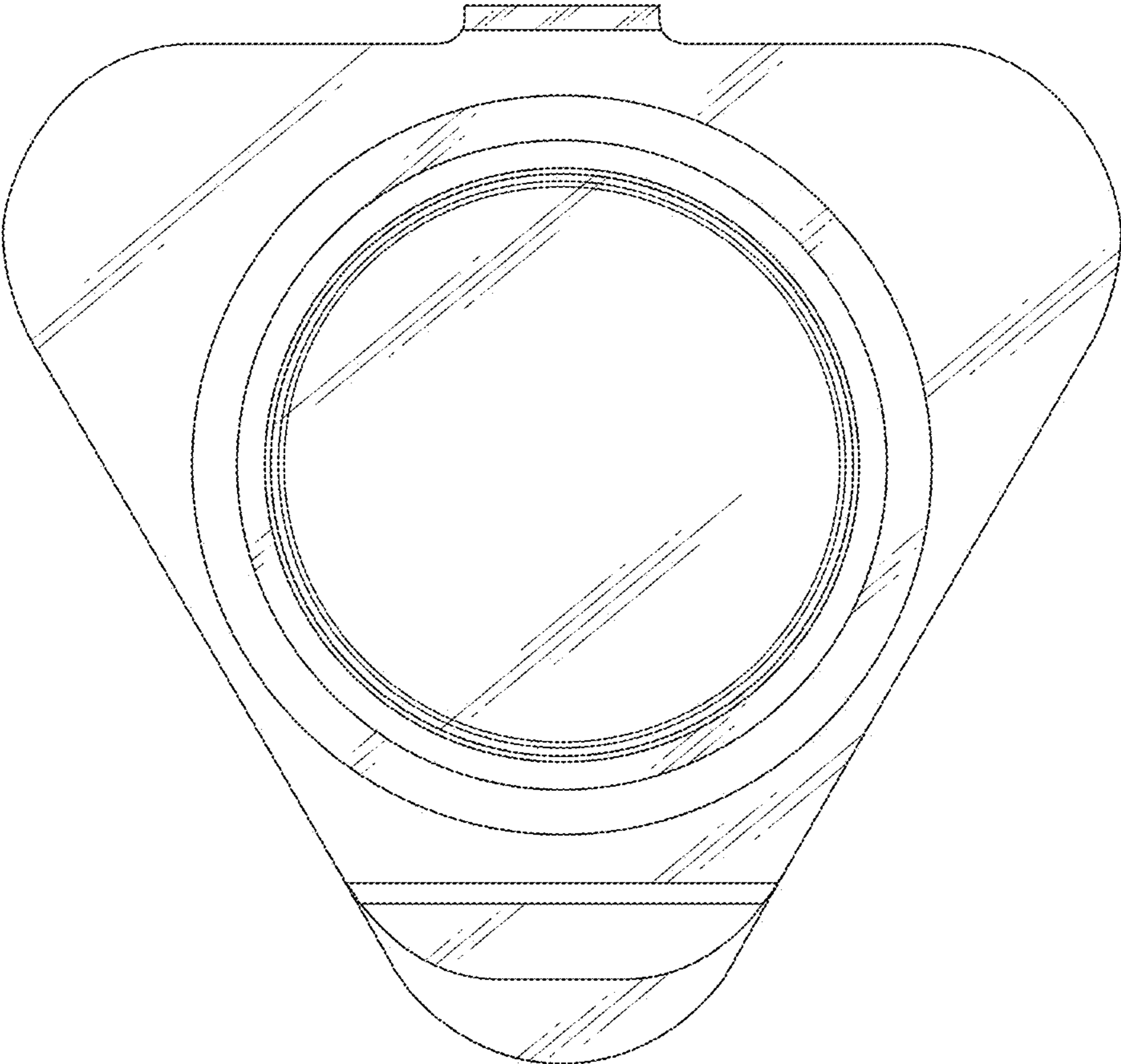


FIG.2

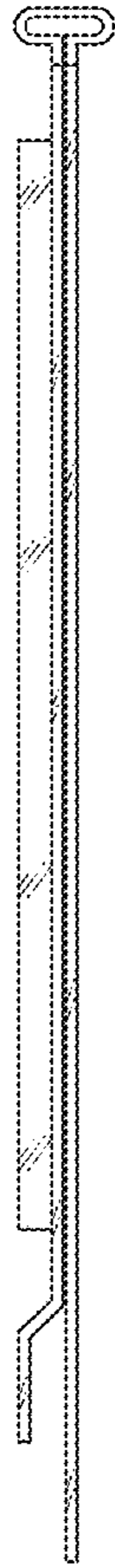


FIG.3



FIG.4



FIG. 5

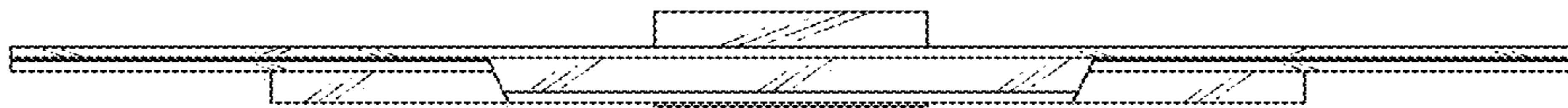


FIG. 6

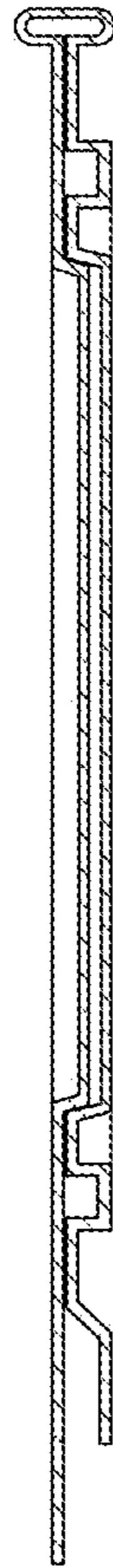


FIG.7

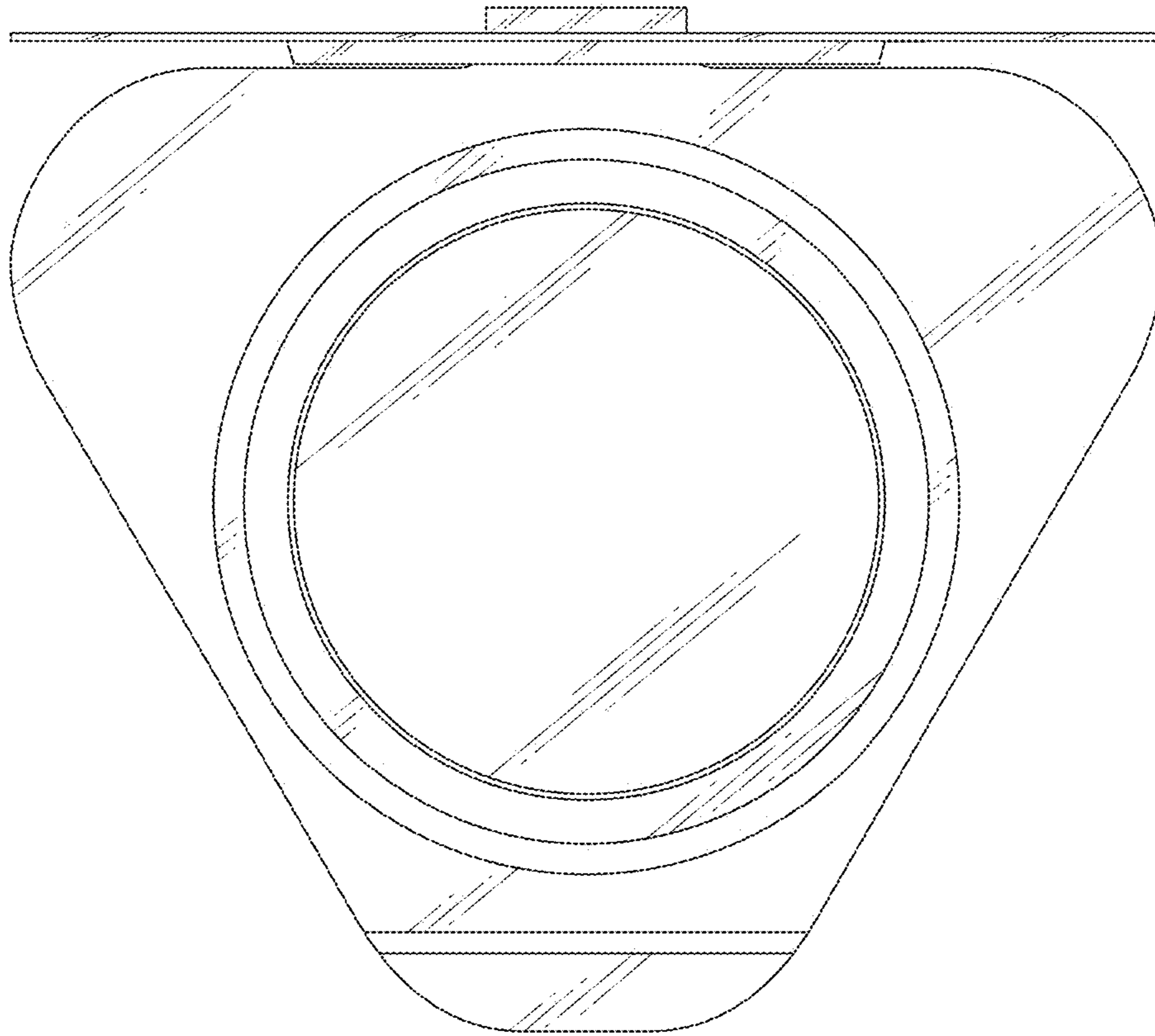


FIG.8



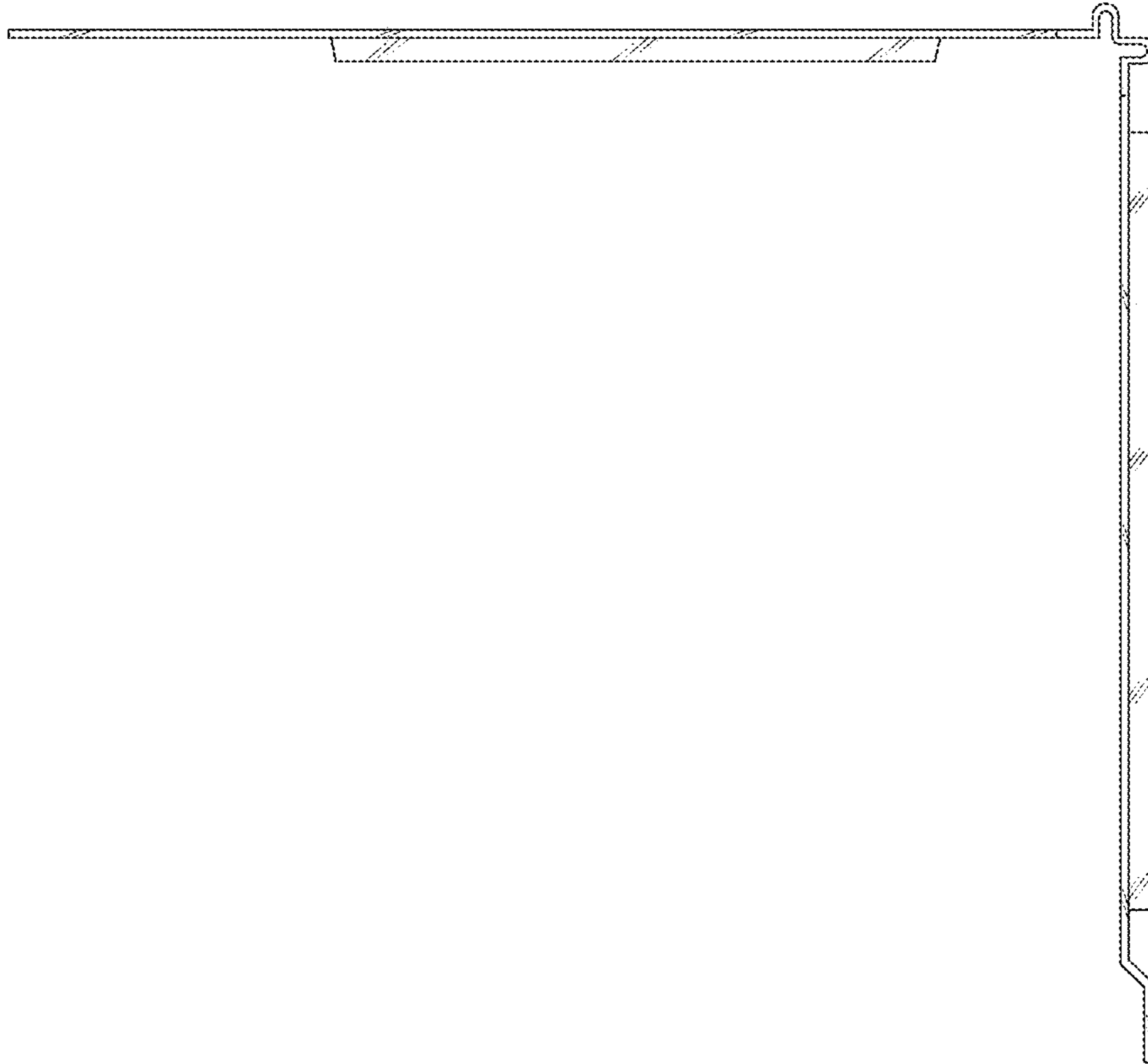


FIG.9